Cite this: DOI: 10.1039/c0xx00000x

www.rsc.org/xxxxx

## **COMMUNICATION**

## **Supporting Information**

## High-Efficiency Inverted Organic Solar Cells with Polyethylene oxide-5 Modified Zn-doped TiO<sub>2</sub> as Interfacial Electron Transport Layer

M.Thambidurai,<sup>\*a‡</sup> Jun Young Kim,<sup>a‡</sup> Youngjun Ko,<sup>a</sup> Hyung-jun Song,<sup>a</sup> Hyeonwoo Shin,<sup>a</sup> Jiyun Song,<sup>a</sup> Yeonkyung Lee,<sup>a</sup> N.Muthukumarasamy,<sup>b</sup> Dhayalan Velauthapillai,<sup>c</sup> and Changhee Lee<sup>\*a</sup>

10 a Department of Electrical and Computer Engineering, Global Frontier Center for Multiscale Energy Systems, Seoul National University, Seoul 151-744, Republic of Korea. Fax:+82-2877-6668; Tel:+82-2880-9093; E-mail: chlee7@snu.ac.kr (Changhee Lee), E-mail: phy\_thambi@rediffmail.com (M.Thambidurai)

<sup>b</sup> Department of Physics, Coimbatore Institute of Technology, Coimbatore 641 014, India. Fax: +91-0422-2575020; 15 Tel: +91-94429-54202; E-mail: vishnukutty2002@yahoo.co.in

<sup>c</sup> Department of Engineering, University College of Bergen, Bergen, Norway. Fax: +4755587030; Tel: +4755587711; E-mail:Dhayalan.Velauthapillai@hib.no

20

25

30

35

40

45

## **Experimental section**

Synthesis of Polyethylene oxide (PEO)-modified Zn-doped TiO<sub>2</sub> nanocrystalline thin films: In the present study, PEO-modified Zn-doped TiO<sub>2</sub> nanocrystalline thin films have been prepared using solgel spin coating method. Titanium (IV) butoxide (Ti(OCH<sub>2</sub>CH<sub>2</sub>CH<sub>2</sub>CH<sub>3</sub>)<sub>4</sub>) (0.45M) and zinc acetate 5 dihydrate (Zn(CH<sub>3</sub>COO).2H<sub>2</sub>O) (0.01M) were dissolved in a mixture of 2-methoxyethanol (CH<sub>3</sub>OCH<sub>2</sub>CH<sub>2</sub>OH) and acetylacetone (CH<sub>3</sub>COCH<sub>2</sub>COCH<sub>3</sub>) (0.45M) at room temperature. The resultant solution was stirred for 1h to yield a homogeneous, clear and transparent (light yellowish color) solution using magnetic stirrer. Polyethylene oxide (PEO) (0.01 wt.%, 0.05 wt.%, 0.1 wt.% and 0.3 wt.%) was dissolved in chlorobenzene. The PEO solution was slowly added to Zn-doped TiO<sub>2</sub> sol 10 and was stirred for 2h to obtain the final sol ready for deposition of thin films. The spin coating method was used to prepare thin films of PEO-modified Zn-doped TiO<sub>2</sub> onto ITO substrates using the prepared sol. PEO-modified Zn-doped TiO<sub>2</sub> thin films of thickness 30 nm was formed after post annealing at 500 °C for 1h and these films form the PEO-modified Zn-doped TiO<sub>2</sub> nanocrystalline thin films.

15 Device fabrication and characterization: Inverted organic solar cells (IOSCs) were constructed with a device structure of ITO/PEO:Zn-doped TiO<sub>2</sub> (ZTO)/active layer/MoO<sub>3</sub>/Al. Patterned ITO-coated glass substrates were cleaned by a sequence of sonication in acetone, isopropyl alcohol and deionized water respectively for 15 minutes and UV-ozone cleaning for 10 minutes. A thin layer of PEO-modified ZTO (30 nm) was spin coated onto the ITO substrates and annealed at 500 °C for 2 hours in 20 air. The PEO-modified ZTO substrates were transferred into a glove box. The PTB7:PC<sub>71</sub>BM blend solution was prepared with a weight ratio of 1:1.5 in a mixed solvent of chlorobenzene/1,8-diiodooctane (97:3 vol.%). The active layer (PTB7:PC<sub>71</sub>BM) was then spin-coated on the PEO-modified ZTO layer and the thickness was about 80 nm. After that the organic layer was slowly dried in vacuum, a layer of MoO<sub>3</sub> (10 nm)/Al (100 nm) as electrode was thermally evaporated on top of the

active layer through a shadow mask under a pressure of  $\sim 10^{-6}$  Torr. The effective area of the device was measured to be 0.0196 cm<sup>2</sup>.

Ultraviolet photoelectron spectroscopy (UPS) measurement was performed using AXIS Ultra DLD (KRATOS Inc.) with He I (21.2 eV) as monochromatic light source. X-ray photoelectron 5 spectroscopy (XPS, AXIS-HSi) spectra was used to identify the surface elements and their chemical state. Photoluminescence (PL) spectra of the samples were measured using a Monochromator (SP2150i) and an excitation wavelength 375 nm. Surface topography was studied using atomic force microscopy (Park systems, XE-100). The optical properties were studied using the absorbance spectra recorded using Beckman DU-70 spectrophotometer. The thickness of the films were measured using a 10 Dektak XT surface profiler. The electrical resistivity was measured by a four-point probe method. The mobility was measured by bottom-gate top-contact thin film transistor (TFT) method with semiconductor parameter analyzer (Agilent 4155C). Current density – voltage (J-V) characteristics of the devices were recorded using a Keithley 237 source measurement unit using a 100 mW/cm<sup>2</sup> AM 1.5G solar simulator (Newport, 91160A). Light intensity was calibrated using a standard silicon solar

15 cell as a reference. The incident photon to charge carrier efficiency (IPCE) spectra of the devices were recorded using a lock-in amplifier (Model 7265, Signal Recovery) and a monochromatic light from a xenon lamp through the monochromator (SpectroPro-150, Acton Research Corporation).

20

25



Figure S1. UPS spectra of (a) TiO<sub>2</sub>, 0.05wt.% PEO:TiO<sub>2</sub> and (b) ZTO, 0.05wt.% PEO:ZTO films 30

35

40



30

Figure S2. Absorption spectra of (a) TiO<sub>2</sub>, 0.05wt.% PEO:TiO<sub>2</sub> and (b) ZTO, 0.05wt.% PEO:ZTO films

40

Table S1: Valan	ice band, condu	ction band and	band gap of	$TiO_2, 0.05wt.9$	% PEO:TiO <sub>2</sub> ,	ZTO and
0.05wt.% PEO:Z	ZTO films.					

ETLs	Valence band maximum (VBM) [eV]	Conduction band minimum (VBM) [eV]	Band gap (Eg) [eV]
TiO <sub>2</sub>	-7.66	-4.46	3.20
0.05 wt.% PEO: TiO <sub>2</sub>	-7.61	-4.41	3.20
ZTO	-7.90	-4.60	3.30
0.05 wt.% PEO: ZTO	-7.92	-4.62	3.30



Figure S3. XPS spectra of TiO<sub>2</sub> and ZTO films (a) Ti2p, (b) O1s and (c) Zn2p



Figure S4: Absorption spectra of TiO<sub>2</sub> and ZTO films



Figure S5. TFT device structure and transfer characteristics of  $TiO_2$  and ZTO TFTs

5

The mobility has been measured by bottom-gate top-contact thin film transistor (TFT) method. The TFT device structure is shown in figure S5; SiO<sub>2</sub> was used as the gate dielectric layer, and Al was used as the source/drain electrode. Transfer characteristics of the TiO<sub>2</sub> and ZTO thin film transistors (TFTs) are shown in figure S5. The mobility TiO<sub>2</sub> and ZTO thin films are  $3.15 \times 10^{-4}$  cm<sup>2</sup> V<sup>-1</sup> s<sup>-1</sup> and  $25 3.20 \times 10^{-4}$  cm<sup>2</sup> V<sup>-1</sup> s<sup>-1</sup>.



**Figure S6**. (a) Illuminated J-V, (b) dark J-V characteristics and (c) IPCE spectra of PTB7:PC<sub>71</sub>BM based IOSCs with ETLs of TiO<sub>2</sub> and PEO:TiO<sub>2</sub>.



**Figure S7**. (a) Illuminated J-V, (b) dark J-V characteristics and (c) IPCE spectra of PTB7:PC<sub>71</sub>BM 25 based IOSCs with ETLs of ZTO and PEO:ZTO.



**Figure S8**. The stability of the PTB7:PC<sub>71</sub>BM based inverted device fabricated using TiO<sub>2</sub>, 0.05 wt.% PEO:TiO<sub>2</sub>, ZTO and 0.05 wt.% PEO:ZTO as an electron transport layer

The use of metal oxides on both sides of the PTB7:PC<sub>71</sub>BM layer prevents the diffusion of moisture into the active layer. The stability of the inverted PTB7:PC<sub>71</sub>BM solar cells (with MoO<sub>3</sub> as the hole transport layer and TiO<sub>2</sub>, 0.05 wt.% PEO:TiO<sub>2</sub>, ZTO or 0.05 wt.% PEO:ZTO as the electron transport layer) is shown in Figure S8. The solar cells were exposed continuously to air at room 20 temperature (without any encapsulation barrier). We observed that TiO<sub>2</sub>, 0.05 wt.% PEO:TiO<sub>2</sub> based devices almost retains its original efficiency even after 30 days under ambient conditions with reduction of power conversion efficiency (PCE) from 6.98 to 6.72 % and 7.51 to 7.30 %, while for the device fabricated using ZTO and 0.05 wt.% PEO:ZTO ETL the PCE decreased 7.67 to 7.32 % and 8.10 to 7.82 % under the same conditions. This clealy shows that TiO<sub>2</sub>, PEO:TiO<sub>2</sub>, ZTO and PEO:ZTO 25 based devices exhibit good stability.



Figure S9: PL spectra of TiO<sub>2</sub> and PEO:TiO<sub>2</sub> films



Figure S10: PL spectra of ZTO and PEO:ZTO films



20 Figure S11: AFM images of (a)  $TiO_2$  and  $PEO:TiO_2$  films (b) 0.01 wt.% PEO, (c) 0.05 wt.% PEO,

(d) 0.1 wt.% PEO, (e) 0.3 wt.% PEO



Figure S12: AFM images of (a) ZTO and PEO:ZTO films (b) 0.01 wt.% PEO, (c) 0.05 wt.% PEO, (d) 0.1 wt.% PEO, (e) 0.3 wt.% PEO